L Number	Hits	Search Text	DB	Time stamp
1	2331	polyimide and plasma adj etching	USPAT:	2002/02/19 08:21
			US-PGPUB;	
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2	197	polyimide near3 coating and plasma adj etching	USPAT:	: 2002/02/19 08:49
			US-PGPUB;	1
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3	0	polyimide near3 coating and gas adj distribution adj plate	USPAT;	2002/02/19 08:50
			US-PGPUB;	
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4	. 0	polyimide near3 coating and chamber adj liner	USPAT;	2002/02/19 08:51
			US-PGPUB;	
			EPO; JPO;	
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5	0	polyimide near3 coating and focus adj ring	USPAT:	2002/02/19 08:51
			. US-PGPUB:	
			EPO; JPO;	
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7	693	polyimide and (focus adj ring or chamber adj liner or gas adj distribution	USPAT:	2002/02/19 08:53
		adj plate or confinement adj ring or pedestal)	US-PGPUB;	, 2002, 02, 1, 00.33
		and prints of commont and ring of positions,	, EPO; JPO;	
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6	102	polyimide and (focus adj ring or chamber adj liner or gas adj distribution	USPAT:	2002/02/19 09:00
	102	adj plate or confinement adj ring)	US-PGPUB:	2002/02/17 07.00
		adj plate of commement adj fing)	EPO; JPO;	İ
			DERWENT	
9	0	polyimide near coating and (focus adj ring or chamber adj liner or gas adj	USPAT;	2002/02/19 08:58
,	U	distribution adj plate or confinement adj ring)	US-PGPUB;	2002/02/19 08.38
		distribution adj plate of commencia adj ring)	EPO; JPO:	•
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8	86	polyimide and (focus adj ring or chamber adj liner or gas adj distribution	,	2002/02/19 08:59
0	80	adj plate or confinement adj ring or pedestal) near5 c oated	USPAT; US-PGPUB;	2002/02/19 08.39
		adj plate of confinement adj fing of pedestar) hears e bated	EPO; JPO;	
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10	19	malulacido and (faqua adi vina an abamban adi linan an aga adi diatributian	USPAT:	2002/02/19 09:01
10	19	polyimide and (focus adj ring or chamber adj liner or gas adj distribution adj plate or confinement adj ring or pedestal) near5 coated	US-PGPUB:	2002/02/19 09.01
		adj prate or commement adj ring or pedesiar) near5 coated		1
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	46	matriarida and (facus adi rina an shambar adi linar an aca adi distribution	t .	. 2002/02/10 00:26
11	46	polyimide and (focus adj ring or chamber adj liner or gas adj distribution	USPAT; US-PGPUB:	; 2002/02/19 09:26
		adj plate or confinement adj ring) and contamination	EPO; JPO;	
			DERWENT	1
12	5	plasma adj sprayed near5 polyimide	USPAT:	2002/02/19 09:08
12	5	piasma auj sprayeu nearo porymnue	US-PGPUB:	1 2002/02/17 07.08
			EPO; JPO;	•
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12	40	"4794250"	USPAT:	± 2002/02/19 09:28
13	49	"4786359"	1 '	2002/02/19 09:28
			US-PGPUB;	
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		# 1 TO (2 TO)	DERWENT	2002/03/10 00:25
14	44	"4786359".uref.	USPAT:	2002/02/19 09:35
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j			EPO; JPO;	
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15	I	·	USPAT	2002/02/19 09:32
16	1		USPAT	2002/02/19 09:32
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18	5	5622565.uref.	USPAT;	2002/02/19 09:33
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24	1		USPAT	2002/02/19 09:34
25	1		USPAT	2002/02/19 09:34
26	1		USPAT	2002/02/19 09:34
27	5	"4786359".uref. and polyimide		2002/02/19 09:39
- '		Trosportation and polyminae	US-PGPUB:	,
			' EPO; JPO;	'
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28	6	"4786359" and polyimide	USPAT:	2002/02/19 09:39
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29	88	118/723r and polyimide	USPAT:	2002/02/19 09:42
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_	5643	428/457	USPAT;	2002/02/15 10:44
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-	0	428/457 and plasma adj reactor adj component	USPAT;	2002/02/15 10:44
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-	385	428/457 and plasma and component and coating	USPAT;	2002/02/15 10:45
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	226	429/457 and planes and community and continue and adhering		2002/02/15 10:45
-	220	428/457 and plasma and component and coating and adhesion	USPAT:	' 2002/02/15 10:45
			US-PGPUB;	İ
			EPO; JPO;	
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-	22	428/457 and plasma and component and coating and adhesion near5	USPAT;	2002/02/15 10:46
		polymer	[†] US-PGPUB:	. !
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_ 1	11	"5268200"	USPAT:	[[] 2002/02/15 10:51 [[]
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-	14	(plasma and coated and component).ti.		2002/02/13 10.32
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-	84	(plasma and coating and component).ti.	USPAT;	2002/02/15 10:54
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_	11	(plasma and coating and component).ti.and adhesion	USPAT;	2002/02/15 10:54
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1	21	(plasma and reactor and component).ti.	1	2002/02/15 10:55
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-	5	"5916454"	USPAT;	2002/02/15 12:30
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	529	plasma and chamber and polymer near5 adhesive	USPAT:	2002/02/15 12:36
	327	plasma and chamber and polymer hears admestive	US-PGPUB;	1
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1 -	2	¹ "6120640"	USPAT:	2002/02/15 12:38
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-	7	gas adj distribution adj plate near5 coated	USPAT:	2002/02/15 12:40
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_	8	gas adj distribution adj plate near5 coating	USPAT;	2002/02/15 12:40
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	20	and add distribution add master and an initial		2002/02/15 12:44
-	29	gas adj distribution adj plate and polyimide	USPAT:	· 2002/02/13 12.44 1
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-	49	"4786359"	USPAT; US-PGPUB:	2002/02/15 12:45
			EPO; JPO;	1 1
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-	14645	plasma and ceramic and coating	USPAT;	2002/02/15 12:46
			US-PGPUB;	
			EPO; JPO:	:
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-	1481	428/688	USPAT;	2002/02/15 12:46
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	0405		DERWENT	
•	9405	plasma and component and ceramic and coating	USPAT:	1 2002/02/15 12:47
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_	. 227	428/688 and plasma and ceramic	DERWENT USPAT;	2002/02/15 12:48
•	. 227	1 120/000 and plasma and ectamic	US-PGPUB;	1 2002/02/13 12:46
			EPO: JPO:	
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_	1525	(plasma and component and ceramic and coating) and silicon adj carbide	USPAT:	2002/02/15 12:48
		(present and component and coming) and smooth adjuditie	US-PGPUB:	2002/02/13 12:40
		·	EPO; JPO;	1
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•	749	(plasma and component and ceramic and coating) and silicon adj carbide	USPAT;	2002/02/15 12:48 1
		and chamber	US-PGPUB:	
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-	57185	428/688 and plasma and ceramic silicon adj carbide	USPAT:	2002/02/15 12:48
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-	60964	428/688 and plasma and ceramic adn silicon adj carbide	USPAT;	1 2002/02/15 12:48
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	67	430/600 and places and accoming and allies and allies.	DERWENT	2002/02/15 12:40
•	67	428/688 and plasma and ceramic and silicon adj carbide	USPAT; US-PGPUB;	2002/02/15 12:49
			, EPO: JPO:	•
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	12	plasma adj spraying and polymer near4 adhesion and coating	USPAT:	2002/02/15 12:51
Ī	12	plasma adj spraying and polymer near4 admession and coating	US-PGPUB;	. i
		·	EPO; JPO;	
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	0	confinement adj ring and polymer near4 adhesion and coating	USPAT;	2002/02/15 12:51
			US-PGPUB:	F .
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-	, 0	focus adj ring and polymer near4 adhesion and coating	USPAT:	2002/02/15 12.52
			US-PGPUB;	1
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•	30	pedestal and polymer near4 adhesion and coating	USPAT;	2002/02/15 12:53
			US-PGPUB:	
			† EPO; JPO; DERWENT	l ,
	1031	plasma and polymer near4 adhesion and coating	USPAT;	2002/02/15 12:53
	1031	prasma and polymer near4 admeston and coating	US-PGPUB:	2002/02/13 12:33
			EPO; JPO;	
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_	0	plasma and polymer near4 adhesion and coating and focus adj ring	USPAT;	2002/02/15 12:53
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-		60	plasma and polymer near4 adhesion and coating and focus	USPAT:	2002/02/15 12:54
				US-PGPUB;	1 :
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_		104	plasma adj reactor and gas adj distribution adj plate	USPAT:	2002/02/15 12.56
			process and gas and converse and pract	US-PGPUB:	
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-		0	plasma adj reactor and gas adj distribution adj plate and polymer adj	USPAT;	2002/02/15 12:56
			adhesion	ÜS-PGPUB;	1
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-		5	plasma adj reactor and polymer adj adhesion	USPAT:	2002/02/15 12:56
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_	1	0	plasma adj reactor and gas adj distribution adj plate near5 (polymer adj	USPAT;	2002/02/15 12:57
	1	·	adhesion)	US-PGPUB:	2002/02/15 12:57
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•		0	plasma adj reactor and gas adj distribution adj plate and (polymer near5	USPAT:	1 2002/02/15 12:58 1
			adhesion)	US-PGPUB;	i '
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_		51	plasma adj reactor and (polymer near5 adhesion)	USPAT;	2002/02/15 12:58
		٥.	plasma adj reactor and (porymer hears adhesion)	US-PGPUB;	2002/02/13 12:30
				EPO; JPO;	! !
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-	İ	20	plasma adj reactor and (polymer near5 adhesion) and polyimide	USPAT;	2002/02/15 12:59
				US-PGPUB:	ļ
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-		25	plasma adj reactor and gas adj distribution adj plate and polyimide	USPAT;	2002/02/15 13:00
				† US-PGPUB: EPO; JPO;	1
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_		15	plasma adj reactor and gas adj distribution adj plate and polyimide and	USPAT;	: 2002/02/15 13:01 i
			polymer	US-PĞPUB:	
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-		0	coating and "gas distibuion plate"		2002/02/15 13:01
	}			US-PGPUB:	
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-		0	coating and "gas distibution plate"	USPAT; US-PGPUB;	2002/02/15 13:01
	1			EPO; JPO;	
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_	-	236	coating and "gas distribution plate"	USPAT;	2002/02/15 13:04
	1	230	county and gas distribution plant	US-PGPUB;	
				EPO: JPO:	!
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÷		8	coating near5 "gas distribution plate"	USPAT;	2002/02/15 13:02
				+ US-PGPUB;	1
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		333		DERWENT	2002/02/15 13:05
		444	component and polyme radi ashesion near5 coating	' USPAT;	2002/02/13 13:03
		555		DS-PCPUR-	
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-	0	component and polymer adj ashesion near5 coating	USPAT:	2002/02/15 13:17
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-	4024	plasma adj chamber and c oated	USPAT;	2002/02/15 13:18
			US-PGPUB:	
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-	1253	plasma adj chamber and coated	USPAT:	2002/02/15 13:21
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_	48	plasma adj chamber and adhesion adj coating	USPAT:	1 2002/02/15 13:25
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	39	placeme adi abambar and adhasian adi sautina and anti-	DERWENT	1 2002 (2011 12 22
-	39	plasma adj chamber and adhesion adj coating and polymer	USPAT;	2002/02/15 13:22
		·	US-PGPUB;	į
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-	5	"5916454"	USPAT:	2002/02/15 13:26
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-	2	"5916454".uref.	USPAT:	¹ 2002/02/15 13:35 ¹
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-	1493	plasma adj coating	USPAT;	2002/02/15 13:35
			US-PGPUB:	'
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-	423	plasma adj coating and adhesion	USPAT:	2002/02/15 13:35
			US-PGPUB;	
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_	2	plasma adj coating and polymer adj adhesion	USPAT;	2002/02/15 13:36
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_	36	plasma adj coating and adhesion and roughness and ceramic	USPAT:	2002/02/15 13:38
-	30	Prasma adj coating and adhesion and roughness and ceramic	US-PGPUB:	- 400404121212.20 !
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-	567	chamber and adhesion and roughness and ceramic and plasma and ceramic	USPAT: US-PGPUB:	2002/02/15 13:36
			EPO: JPO:	1
	115		DERWENT	
-	480	chamber and adhesion and roughness and ceramic and plasma and oxide	USPAT;	2002/02/15 13:37
		one was a second and roughtness and column and plasma and oxide	US-PGPUB;	1
			EPO; JPO;	<u> </u>
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•	60	plasma adj coating and adhesion and roughness	USPAT:	2002/02/15 13:37
		process and admission and roughness	US-PGPUB;	1 2002/02/15 15.57
			EPO: JPO:	Ť
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	1253	plasma adj chamber and coated	USPAT.	2002,02,15 13:38
	1		US-PGPUB:	2002/02/15 15.50
	1	,	EPO; JPO;	
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	84	plasma adj chamber near5 coating	USPAT;	2002/02/15 13:38
			US-PGPUB;	1 2222.02.15 15.50
			EPO; JPO;	
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	477	"plasma sprayed coating"	USPAT;	2002/02/15 13:39
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			[†] EPO: JPO:	
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	67	plasma adj chamber near5 coated	USPAT;	2002/02/15 13:39
		F	US-PGPUB:	2002/02/13 13:37
	1		EPO; JPO;	1
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	47	"plasma sprayed coating" and adhesion and chamber	USPAT;	2002/02/15 13:43
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	22	"plasma sprayed coating" and adhesion and chamber and polymer	USPAT.	2002/02/15 13:42
		h	US-POPUB;	
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	1474732	"plasma sprayed coating" and focus ring	USPAT:	2002/02/15 13:44
			US-PGPUB;	
			EPO; JPO;	
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	0	"plasma sprayed coating" and "confinement ring"	USPAT,	1 2002/02/15 13:44
			US-PGPUB:	•
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	1	"plasma sprayed coating" and "focus ring"	USPAT:	2002/02/15 13:44
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			EPO; JPO;	
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	7	"plasma sprayed coating" and "pedestal"	USPAT;	2002/02/15 13:44
			US-PGPUB,	
			EPO; JPO;	i
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	6	"plasma sprayed coating" and gas adj distribution	USPAT:	2002/02/15 13:47
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	-1	"plasma sprayed coating" and chamber adj line\$	USPAT;	2002/02/15 13:47
		•	US-PGPUB;	
			EPO; JPO;	1
			DERWENT	1
	13	"plasma sprayed coating" and chamber adj wall	USPAT:	2002/02/15 13:48
			US-PGPUB:	
		•	FPO, JPO,	
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-	4843	chamber adj wall and coating	USPAT:	2002-02-15-13(53
l	1	i	US-PGPUB;	2002 02 15 15(5)
			EPO; JPO;	:
			DERWENT	!
-	23	gas adj distribution near5 coated	USPAT:	2002/02/15 13:49
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			EPO; JPO;	į
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-	34	gas adj distribution near5 coating	USPAT:	2002/02/15 13:50
			US-PGPUB.	
		ı	FPO; JPO;	
			DERWENT	1
-	36	chamber adj wall near5 coated and polymer	USPAT:	2002/02/15 13:55
			US-PGPUB;	
			EPO: JPO:	,
			DERWENT	
-	10	5423918.uref.		2002/02/15 13:58
			US-PGPUB:	
			EPO; JPO;	
			DERWENT	
-			USPAT	2002-02 15 13-57
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1.	60	coated near5 process adj chamber		2002/02/15 13:57 ! 2002/02/15 14:00 ;
	00	content process and enumber	US-PGPUB:	2002/02/13 14:00
			EPO; JPO;	
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-	1481	428/688		2002/02/15 14:00
			US-PGPUB;	1
			EPO; JPO;	
İ			DERWENT	1
-	396	428/688 and plasma	USPAT;	2002/02/15 14:00
			US-PGPUB;	i
			EPO: JPO:	
			DERWENT	
-	287	428/688 and plasma and coating	•	2002/02/15 14:01
			' US-PGPUB:	
			EPO; JPO; DERWENT	ŀ
	0	"08393527"	<u>.</u>	2002/02/15 14:01
-	0	08373327	US-PGPUB;	2002/02/13 14.01
			EPO; JPO:	!
			DERWENT	i
_	21	"5494523"		2002/02/15 14:16
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-	1	·	USPAT	2002/02/15 14:05
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-	1			2002/02/15 14:10
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	29	5085727.uref.	USPAT:	2002/02/15 14:22
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•	1 20	5005707	USPAT	2002/02/15 14:21
-	29	5085727.uref. and gas	USPAT;	2002/02/15 14:22
İ	1		US-PGPUB:	,
			EPO: JPO;	
			DERWENT	
-	11	5085727.uref. and gas adj distribution	USPAT;	2002/02/15 14:24
			' US-PGPUB:	
			† EPO; JPO;	1
}			DERWENT	
-	1		USPAT	2002/02/15 14:23
-	1		USPAT	2002/02/15 14:23
-	0	plasma adj reactor near5 component and coating near roughness	USPAT;	2002/02/15 14:24
!	ţ		¹ US-PGPUB:	
	1		EPO, JPO;	!
			DERWENT	i
-	0	plasma adj reactor near5 component and coating near rough	, USPAT;	2002/02/15 14:24
1			US-PGPUB:	4
			' EPO; JPO;	1
		·	DERWENT	
-	4	plasma adj reactor near5 component and polyimide	+ USPAT;	2002/02/15 14:25 ;
l			US-PGPUB;	
			EPO; JPO;	
			DERWENT	
-	154	plasma adj reactor and component and polyimide	USPAT;	2002/02/15 14:25
	1		US-PGPUB;	1
		·	EPO; JPO;	!
			DERWENT	i i
-	6	plasma adj reactor and component and polyimide near5 coating	USPAT:	2002/02/15 14:26
			US-PGPUB:	
			EPO; JPO;	
		· ·	DERWENT	
-	294	428/458 and plasma	USPAT;	, 2002/02/15 14:26
		·	US-PGPUB:	,
			EPO; JPO;	i 1
		· ·	DERWENT	1
	250	428/458 and plasma and coating	USPAT:	¹ 2002/02/15 14:26 ¹
			' US-PGPUB:	. 1
			EPO: JPO:	
			DERWENT	
-	43	428/458 and plasma and contamination	' USPAT:	¹ 2002/02/15 14:27 ¹
		•	US-PGPUB;	
			EPO; JPO;	
			DERWENT	
-	17	428/458 and plasma and contamination and polyimide	USPAT;	2002/02/15 14:29
			US-PGPUB:	1.
			ЕРО, ЈРО:	
		·	DERWENT	.1
	6	plasma and deposits near5 flake and prevention	' USPAT;	2002/02/15 14:39
			US-PGPUB;	
		· ·	EPO; JPO;	
			DERWENT	1
•	559	427/446	USPAT:	2002/02/15 14:39
			US-PGPUB,	1
			EPO: JPO:	
			DERWENT	
-	6	427/446 and gas adj distribution	USPAT;	2002/02/15 14:40
			US-PGPUB:	!
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•	2	427/453 and gas adj distribution	USPAT: 2002/02/15 14	4:41
i			US-PGPUB;	
			EPO; JPO;	
			DERWENT	
	26	427/447 and polyimide	USPAT; 2002/02/15 1:	5:02
			US-PGPUB;	
			FPO: JPO	
İ			DERWENT	
+	2	5916454.uref.	USPAT: 2002/02/15 1:	5:02
			US-PGPUB:	
			EPO: JPO;	
			DERWENT	
	5	"5916454"	USPAT; 2002/02/15 1:	5:19
			US-PGPUB;	
!			EPO; JPO;	
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	3	4973927.uref.	USPAT; 2002/02/15 1:	5:20
			US-PGPUB;	
			EPO; JPO;	
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			US-PGPUB:	
			EPO; JPO:	
	83	nolvimide and places adjustrated	DERWENT	o. 20
	63	polyimide and plasma adj sprayed	USPAT; 2002/02/19 08 US-PGPUB:	3.20
			EPO: JPO:	
			DERWENT	
	411		USPAT 2002/02/15 15	5.20